

Forward Looking Statements



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Strong platform + favorable market dynamics to enable utilization of electrooptic polymers for high speed, low power AI and data center applications.



Unprecedented Accelerating Demand

- TAM of \$24B and SAM of \$1-2.5B by 2028 are growing quickly
- Driven by CapEx to address AI, quantum, datacomm & space comm requirements



Innovative EO Polymer Technology

- Disruptive technology enabler for future speed upgrades in data bandwidth
- Relieves key bottlenecks in Al infrastructure



Strong Patent Portfolio

- Protected by broad IP portfolio with over 70 patents
- · Numerous patents pending



Deeply Experienced Leadership

 Management, Board of Directors, Advisory Board have 200+ years conceiving and launching products



Robust Balance Sheet

- · Critical for execution
- \$22M+ cash position provides significant optionality and execution runway (as of 6/30/25)



Materials and IP licensing/royalty dual-model for attractive blended gross margin

We are a Material + IP/Royalty Licensing Company



Foundational E/O Polymer R&D...

...For Creating
Next-Gen Optical
Modulators

...And Generating
High Margin
Revenues



E/O Polymer Composition & IP



E/O Polymer Production



Material Sales

Reference Designs & Polymer "PDK" IP



IP & "PDK" Licensing & "Co-Design" Capability



Licensing &/or Royalty Fees

60%+

Gross Margin at Scale

Al Infrastructure Challenges Addressed by Lightwave Logic EO Polymers





BANDWIDTH

CONNECTIVITY

POWER

INTEGRATION

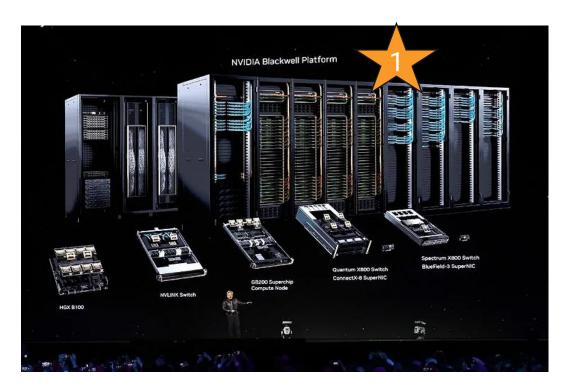
LIGHTWAVELOGIC®

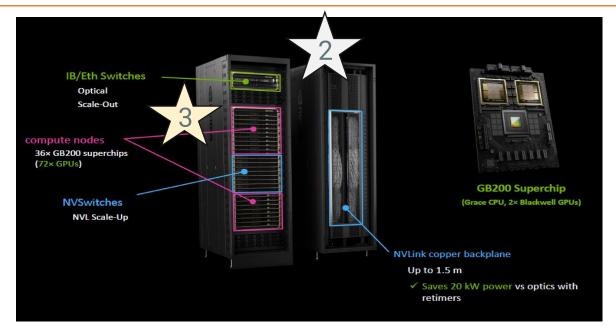
AI Cluster Opportunity





Scale Out – Switch Rack to Switch Rack interconnect using optics (transceiver based)









Scale Out – GPU rack to Switch rack connectivity – migrating to optical cables/CPO

Scale Up – GPU to GPU connectivity – PCB traces migrating to CPO/optical chiplets

Source: Nvidia

AI & Data Center Market Opportunity



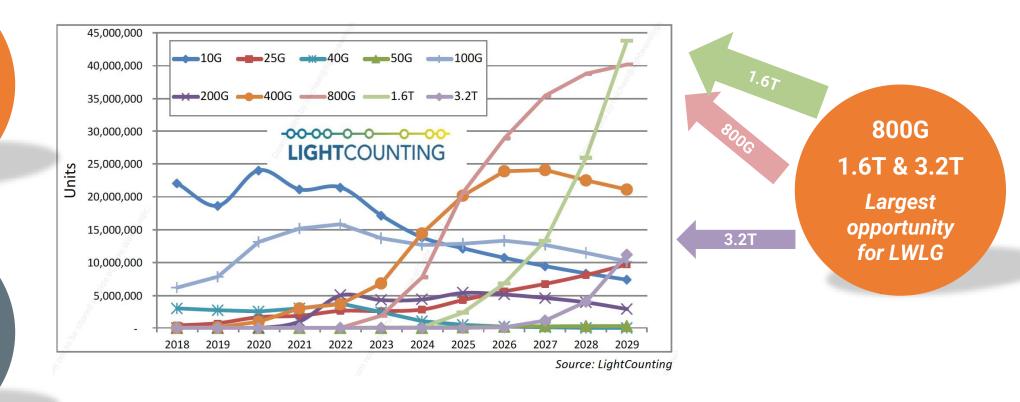
Unprecedented Growth + Opportunity from Global AI Demands and Adoption

>10X

Growth in 800G since 2022

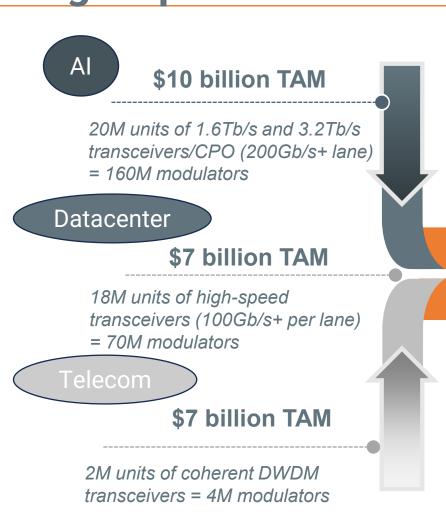
>20X

Forecast growth for 1.6T since 2023



Al/Datacenter and Telecom Opportunity for Ultra High-Speed Modulators





2028 Estimated
Total Addressable Market (TAM)
& Serviceable Addressable Market (SAM)*

\$1.0 - 2.5 billion SAM

Serviceable market for EOP modulators depending on integration level

Potential additional markets (not included):

- Quantum Computing
- Aerospace & Defense
- Consumer Electronics

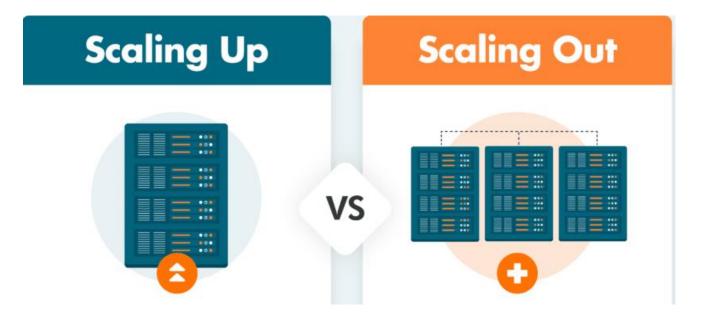
Critical Milestones For LWLG

- Multiple major design wins by 2028 with Tier 1 transceiver and SiPho design houses
- Majority market share for 400Gb/s lane designs
- Technology capable of addressing future customer needs

^{*} Source: LightCounting, internal company estimates

The Emergence of CPO (Co-Packaged Optics)





bandwidth (400G+), low power and ability to integrate with silicon chips

Requires high density ports (size becomes critical), high

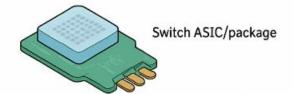
connections with optical links

Excellent fit for Perkinamine®; future proof technology unlike legacy material alternatives

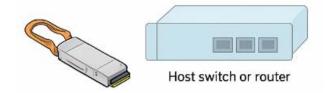
New market emerging to replace very short electrical copper



Co-Packaged Optics (CPO)

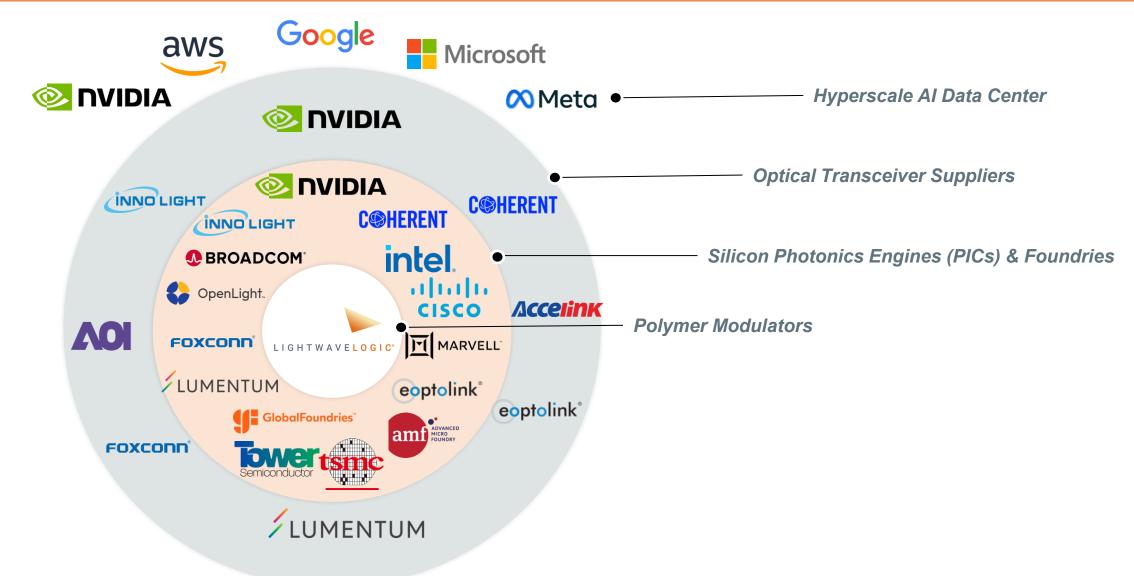


Optical Transceiver Modules



Enabling AI Connectivity Ecosystem





Entering a New Stage for Lightwave Logic



Seizing growth opportunities presented by Al

Stage 1
Complete

Technology & Materials
Development

Patents/IP, Polymers, Factory and Process **Stage 2** 2025 + 2026

Customers & Products

Product Design-ins
Silicon Photonics
Foundries

Al Ecosystem Integration

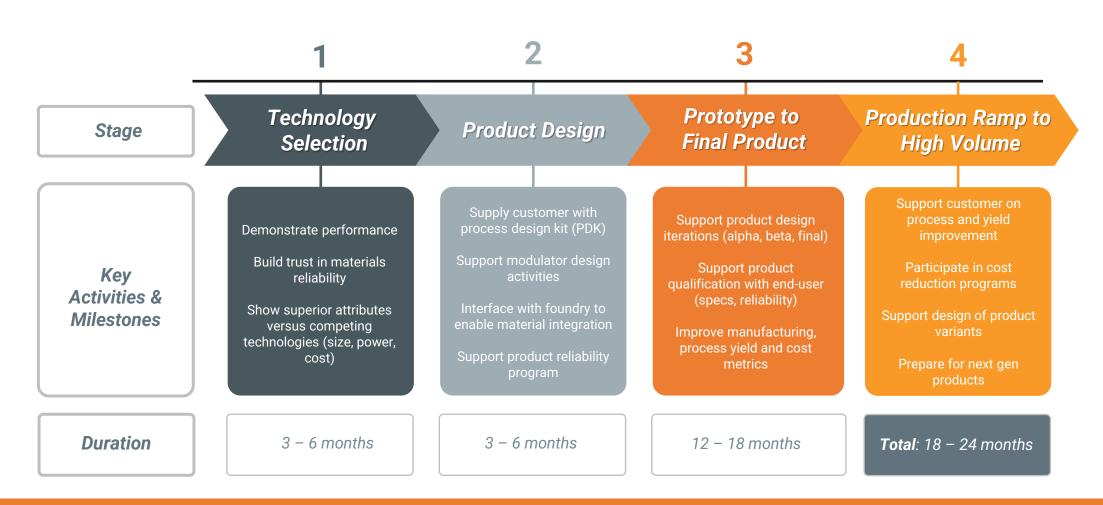
Stage 3 Starting 2026

Scale-up & Diversification

Production infrastructure

New markets and applications

Design Win Cycle



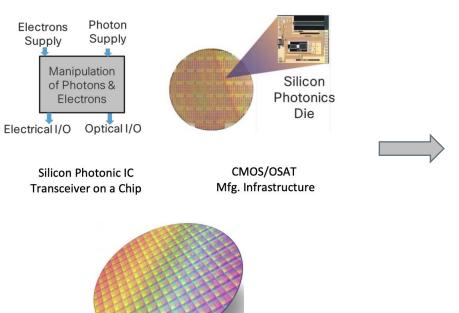
Reaffirming expectation to have 3-5 customers in Stage 3 by year-end 2025

SiPho Meeting its Physical Limits

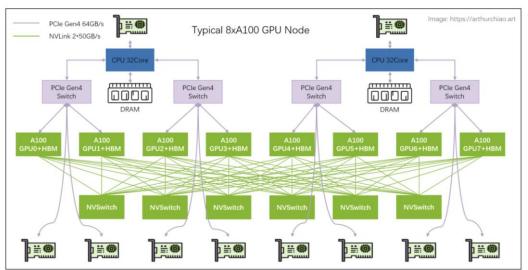


EOP can leverage and supercharge the innovation, scale and infrastructure of SiPho for next gen data speeds

Silicon photonics has enabled the revolution so far...



But AI Clusters are increasing demand for datacom 10x...



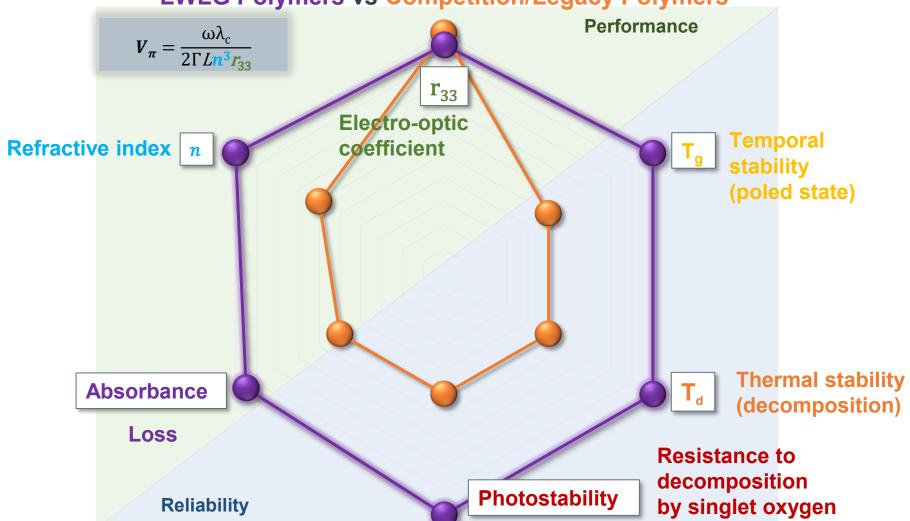
... with optical interconnects growing ∝ 10x cluster size

Silicon Photonics cannot meet bandwidth requirements; Our material is the key difference maker

Lightwave Logic Edge

LWLG EO polymers are world-class in every parameter and designed for reliability

LWLG Polymers vs Competition/Legacy Polymers



EOP Performance vs. Alternative Technology

LWLG EO polymers have inherently high performance and are fully Si-foundry compatible

r₃₃ intrinsically capped at ~ 31 pm/V at 1310 nm n = 2.2, $ε_r = 30$ (high dispersion across frequencies)

Integration with Si/SiN very low yielding & basically still in R&D stage Limited wafer size (150 mm) Large device footprint (sub-cm scale)

High material cost w/ only one supplier (NanoLN)

Thin film uniformity becomes difficult as wafer size scales up Specialized processing/tools needed – leads to higher costs associated with processing, QC, etc.

Electro-optic Polymers

Performance

Integration

Processing

No intrinsic cap on r₃₃ (> 200 pm/V at 1310 nm easily achieved) $n \approx 1.9$, $\epsilon_r \approx 3-6$ (low dispersion across frequencies)

Fully Si compatible

Easily scalable to 300 (+) mm wafer

Very small device footprint (sub-mm scale)

Low material cost

Spin-coating produces films with high uniformity

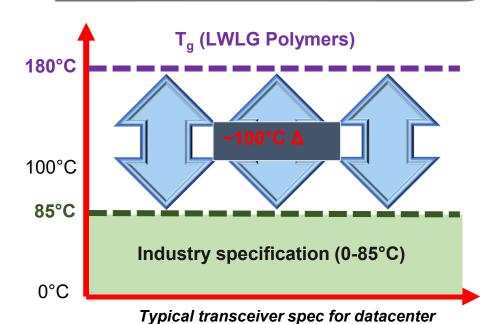
No specialized processing/tools needed (completely compatible with existing Si foundry processes/tools) – reduces costs associated with processing, QC, etc.

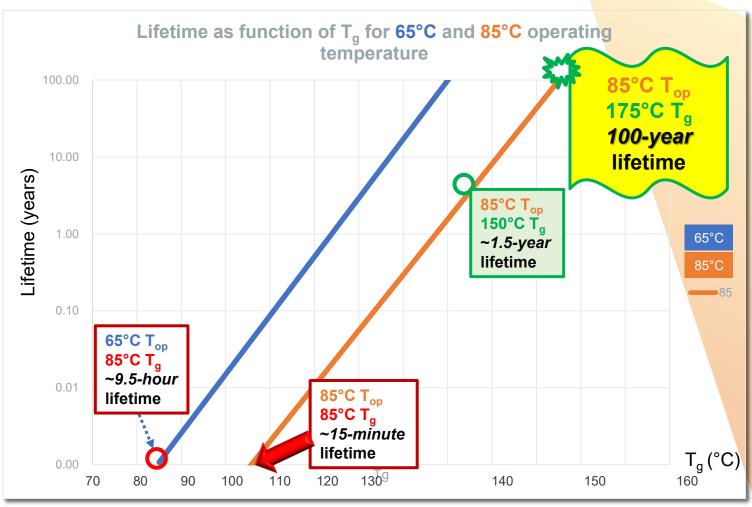
EOP Reliability

LWLG EO polymers are uniquely resistant to de-poling due to high Tg

Temporal Stability = Orientational Stability of Poled State

- Lifetime = 10% loss of poled state
- Increasing T_g of material increases lifetime (protects from loss of performance due to depoling)
- LWLG materials designed for high T_a



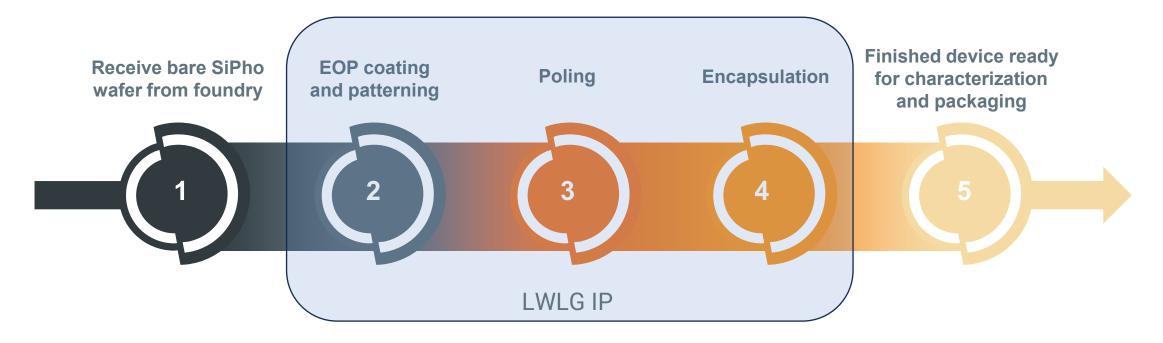


CMOS Compatible Process Flow

Fully compatible and integrable with SiPho foundry process

LWLG Backend/Encapsulation Process:

Currently performed in-house; fully documented and ready for transfer to the foundry



Perkinamine® Reliability Breakthrough



Successful passing of Telcordia GR-468 85/85 environmental stress test validates long-term reliability



Sample Selection

 Thin-film devices with second-generation proprietary encapsulation barrier



Stress Conditions

- 85 °C and 85 % relative humidity for 1,000 hours
 - Industry standard rigorous conditions



Performance

 Change in absorbance measurements showed only 1.6% average loss after 1,000 hours



Pass Rate

More than 11 samples exceeded Telcordia
 GR-468 requirements by a wide margin

- ✓ Confirmation that our EO polymer materials can **maintain performance** over time in harsh operating conditions
- ✓ Similarities with the **trajectory of Organic LEDs** before deployment in real-world applications
- ✓ Robust protection against moisture and oxygen
- ✓ Significant breakthrough with **fourthgeneration atomic layer deposition** (ALD) encapsulation material

Proof of reliability is critical to convince customers to proceed in design win cycle



Critical milestone for Stage 1 & 2 customers, preparing material for on-device reliability



Results have been shared with key customers

Very positive reception and increasing industry's confidence on materials readiness



85/85 Success

• Demonstrates we can protect from oxygen/moisture even with second generation encapsulation addressing historical challenges of EO polymers



Fourth-generation atomic layer deposition (ALD) encapsulation for future requirements

- Oxygen transmission rate (OTR) of 1.4×10^{-6} g/m²/day-approaching the measurement limit of state-of-the-art OTR instrumentation
- This performance far exceeds the "gold-box" standard of 7×10^{-6} g/m²/day for lifetime reliability
- Preparing this fourth-generation encapsulation material for its next-release back-end-of-line (BEOL)
 Process Design Kit (PDK) for integration into silicon photonics foundries



Next step is to demonstrate reliability <u>on devices in partnership with customers</u>

• Focused on continuous improvement of materials, process and encapsulation

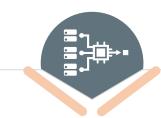
Enhance Operational Excellence to Benefit Tier 1s and Foundries



Key Focus Areas:



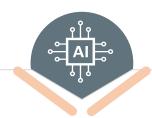
Materials **Production**



Backend Semiconductor Process



Reliability +
Qualification
Toolkit



High-Speed RF Electronics Expertise



Internal
Business
Processes +
People

Adding rigor to our commercialization efforts

Enabling the Utilization of Polymers for Industry Applications

Preparing for commercialization





Reliability Testing

- Successful passing of Telcordia GR-468 85/85 environmental stress test validates long-term reliability
- Conducting photosensitivity testing for high optical power
- Deployed infrastructure for co-testing customer chips for reliability



Scaling Up for Repeatability

- Ramping polymer production equipment for mass production
 - Purchased flow process machine
 - Adding photochemistry processor



Developing Next Generation Polymer/Chromophore for:

- Heterogeneous packaging applications
- Quantum Computing, Aerospace & Defense, and Consumer Electronics applications



Materials Production



Reliability +
Qualification
Toolkit



Customer and Application Support

One of our great values is our expertise in integration and processing



Integration Efforts

- Continuing collaboration on enhancing plasmonic modulators for multi-terabit applications
- Initiating customer-led program to co-design polymer-based SiPH based customer modulators for transceiver applications



Back End of Line (BEOL) Expertise

 Developed polymer "PDK" to seamlessly integrate with Outsourced Semiconductor Assembly and Test (OSAT) and fab "ADK" and related processes for manufacturing modulators



RF Engineering

 Program to assist customer RF teams to model terabit modulators in concert with optical modeling



Backend Semiconductor Process



High-Speed RF Electronics Expertise



LIGHTWAVELOGIC

Positioning company infrastructure for growth and scalability



Drive Operational Excellence

- Completed review of all policies and procedures
- Adding rigor to our technology commercialization process



People

- Optimizing and improving teams across Engineering, Marketing, Reliability, IT and HR
- New Senior VP of Sales & Marketing and new VP of Engineering
- Established sales and distribution channels in Asia via partnership with Photonteck



Facility

- Continuous improvements to in-house BEOL processes with infrastructure transferable to semiconductor foundries
- Enhanced state-of-the-art test and verification lab with improvements to 110 GHz testbed
- "Stress tested" ability to utilize 25,000 square foot facility to scale volume production as required



Internal
Business
Processes +
People



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